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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/006,718	12/10/2001	Mitsuhiro Okuni	740819-711	3646	
22204	7590 04/23/2003				
NIXON PEABODY, LLP			EXAMINER		
SUITE 800	SBORO DRIVE		VINH,	VINH, LAN	
MCLEAN, VA	A 22102		ART UNIT	PAPER NUMBER	
			1765	3	
			DATE MAILED: 04/23/2003		

Please find below and/or attached an Office communication concerning this application or proceeding.

				HC
		Application No.	Applicant(s)	
	•	10/006,718	OKUNI, MITSUHIRO	
***	Office Action Summary	Examin r	Art Unit	$\dashv$
		Lan Vinh	1765	
Period fo	The MAILING DATE of this communicat or Reply	tion appears on the cov r sh et	with the corr spond no address	
THE   - External control contr	ORTENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICA nsions of time may be available under the provisions of 3 SIX (6) MONTHS from the mailing date of this communication of the provision of 3 period for reply specified above is less than thirty (30) do period for reply is specified above, the maximum statutoure to reply within the set or extended period for reply will, reply received by the Office later than three months after the patent term adjustment. See 37 CFR 1.704(b).	TION. 7 CFR 1.136(a). In no event, however, may cation. ays, a reply within the statutory minimum of my period will apply and will expire SIX (6) Not statute, cause the application to become	a reply be timely filed  thirty (30) days will be considered timely.  IONTHS from the mailing date of this communication.  ABANDONED (35 U.S.C. § 133).	
1)⊠	Responsive to communication(s) filed	on <u>10 December 2001</u> .		
2a)	This action is <b>FINAL</b> . 2b)	This action is non-final.		
3)□ Disposit	Since this application is in condition for closed in accordance with the practice ion of Claims	or allowance except for formal r e under <i>Ex parte Quayle</i> , 1935	natters, prosecution as to the merits is C.D. 11, 453 O.G. 213.	
4)⊠	Claim(s) 1-10 is/are pending in the app	plication.		
·	4a) Of the above claim(s) is/are			
5) 🗌	Claim(s) is/are allowed.			
6)⊠	Claim(s) <u>1-10</u> is/are rejected.			
7)	Claim(s) is/are objected to.			
8)[]	Claim(s) are subject to restriction	on and/or election requirement.		
Applicat	tion Papers			
	The specification is objected to by the E			
10)	The drawing(s) filed on is/are: a)	l□ accepted or b)□ objected to t	by the Examiner.	
	Applicant may not request that any object	tion to the drawing(s) be held in at	Devance. See 37 CFR 1.85(a).	
11)	The proposed drawing correction filed of		_ disapproved by the Examiner.	
	If approved, corrected drawings are requi			
• —	The oath or declaration is objected to b	y the Examiner.		
	under 35 U.S.C. §§ 119 and 120		0 5 440(a) (d) 05 (0	
	Acknowledgment is made of a claim for	or foreign prionty under 35 U.S.	C. § 119(a)-(d) of (i).	1
а	)⊠ All b)□ Some * c)□ None of:			
	1. Certified copies of the priority do		- AIliantian No. 10006719	
	2. Certified copies of the priority do			
*	3. Copies of the certified copies of application from the Internat See the attached detailed Office action	tional Bureau (PC1 Rule 17.2(8	i)).	
			C. § 119(e) (to a provisional application).	
	<ul> <li>a)           The translation of the foreign lang          Acknowledgment is made of a claim foreign.</li> </ul>	uage provisional application ha	s been received.	
Attachme				
1) No	tice of References Cited (PTO-892) tice of Draftsperson's Patent Drawing Review (PT ormation Disclosure Statement(s) (PTO-1449) Pap	O-948) 5) 🔲 Notic	riew Summary (PTO-413) Paper No(s) e of Informal Patent Application (PTO-152)	

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## **DETAILED ACTION**

## Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1, 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Miyoshi (US 5,801,101) in view of Kumihashi et al (US 5,368,685)

Miyoshi discloses a method for forming metal wiring by dry etching an aluminum-silicon copper alloy film in the plasma chamber using an etching gas mixture mainly comprises a chlorine gas (col 5, lines 25-28). Mioshi also discloses that t= pV/Q wherein t is the residence time of the gas in the chamber/gas stay time, p: the pressure in the chamber (Torr), V: chamber volume (I), Q: exhaustion amount (Torr.I/sec)/total etching gas flow (col 3, lines 15-25)

Unlike the instant claimed inventions as per claims 1, 6, Miyoshi does not disclose the specific values of the gas stay time/ the residence time of the gas in the chamber and the pressure in the chamber although Miyoshi discloses that the residence time of the gas/gas stay time can be changed by changing/adjusting the pressure in the chamber and the exhaustion amount/total etching gas flow (col 3, lines 32-35)

However, Kumihashi, in a method of dry etching, teaches changing the volume of the etching chamber and volume of the discharge/exhaust part to obtain a specific gas residence time (col 13, lines 11-15)

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Hence, one skilled in the art would have found it obvious to change/adjust Miyoshi's chamber pressure and the exhaustion amount/total flow rate by conducting routine experimentations to obtain the specific value of the gas stay time because Kumihashi serves as evidence that the gas stay time/ the residence time of the gas is a result variable. It has been held that the discovery of an optimum value for result effective variables is within the purview of routine experimentation by the person of ordinary skill in the art. In re Boesch, 617 F.2d 272, 276, 205 USPQ 215, 219 (CCPA 1980)

3. Claims 2, 4, 7, 9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Miyoshi (US 5,801,101) in view of Kumihashi et al (US 5,368,685) and further in view of Nowak et al (US 6,220,201)

Miyoshi as modified by Kumihashi has been discussed above in paragraph 2. Unlike the instant claimed inventions as per claims 2, 4, 7, 9, Miyoshi and Kumihashi do not disclose the specific values of the wafer diameter and the chamber volume.

However, Nowak, in a method of high density plasma etching, teaches that the volume of the chamber changes depending on the size of the wafer (col 7, lines 23-25)

Thus, Novak serves as evidence that volume of the chamber and size/diameter of the wafer are result variable. It has been held that the discovery of an optimum value for result effective variables is within the purview of routine experimentation by the person of ordinary skill in the art. In re Boesch, 617 F.2d 272, 276, 205 USPQ 215, 219 (CCPA 1980)

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4. Claims 3, 5, 8, 10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Miyoshi (US 5,801,101) in view of Kumihashi et al (US 5,368,685) and further in view of Nowak et al (US 6,220,201) and Hynecek (US 4,708,766)

Miyoshi as modified by Kumihashi and Novak has been discussed above in paragraph 3. Unlike the instant claimed inventions as per claims 3, 5, 8,10, Miyoshi, Kumihashi and Novak do not disclose the specific values of the total etching gas flow rate.

However, Hynecek, in a method of dry etching, teaches that the gas flow rate should be adjusted proportionally when the volume of the chamber changes (col 5, lines 26-29)

Hence, one skilled in the art would have found it obvious to change/adjust Miyoshi, Kumihashi and Novak chamber pressure by conducting routine experimentations to obtain the specific flow rate values because Hynecek serves as evidence that the gas flow rate is a result variable. It has been held that the discovery of an optimum value for result effective variables is within the purview of routine experimentation by the person of ordinary skill in the art. In re Boesch, 617 F.2d 272, 276, 205 USPQ 215, 219 (CCPA 1980)

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## Conclusion

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lan Vinh whose telephone number is 703 305-6302. The examiner can normally be reached on M-F 8:30-5:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Benjamin Utech can be reached on 703 308-3836. The fax phone numbers for the organization where this application or proceeding is assigned are 703 872-9310 for regular communications and 703 872-9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703 308-0661.

LV

April 10, 2003